

PATENT APPLICATION

Atty. Docket No.: 2522-033 Serial No. not yet assigned
Applicant: Eung-Joon LEE, In-Sun PARK and Ji-Soon PARK
Filing Date: July 29, 2003 Group: not yet assigned
For: METHOD FOR FORMING SILICIDE FILM OF A SEMICONDUCTOR DEVICE

**INFORMATION DISCLOSURE CITATION
FORM PTO-1449 (Modified)**

U.S. PATENT DOCUMENTS

<u>Exam</u> <u>Init</u>	<u>Ref</u>	<u>Document</u> <u>Number</u>	<u>Issue</u> <u>Date</u>	<u>Name</u>	<u>Class</u>	<u>Sub</u> <u>Class</u>
_____	_____	6,303,503B1	10/16/2001	Kamal et al.		

FOREIGN PATENT DOCUMENTS

<u>Exam</u> <u>Init</u>	<u>Ref</u>	<u>Document</u> <u>Number</u>	<u>Publication</u> <u>Date</u>	<u>Country</u>	<u>Name</u>
_____	_____				

OTHER DOCUMENTS

<u>Exam</u> <u>Init</u>	<u>Ref</u>	<u>Author, Title, Date, Pertinent Pages, Etc.)</u>

Examiner: _____

Date Considered: _____